



RECOMMENDED SKIN TYPES















INGREDIENT HIGHLIGHTS

Niacinamide (Vitamin B3), Tocopheryl Acetate (Vitamin E), Polygonum Aviculare Extract (Knotweed Extract), Sodium Hyaluronate (Hyaluronic Acid)

Radical Defense SPF 45

DESCRIPTION

Radical Defense, a light weight SPF 45, contains an innovative blend of active ingredients. Protecting skin from multiple extrinsic factors known to cause premature aging, including UVA, UVB & Infrared Radiation. Delivering a new strategy in sun protection, Radical Defense SPF 45 will provide the highest possible level of protection while restoring youthfulness to the skin. Derived from Knotweed Extract, our botanically-based active is the first of its kind, preventing damage from infrared radiation, which is believed to be just as detrimental to skin health as UVA & UVB. This fast-absorbing SPF also features a high level of Niacinamide to promote a smoother, clearer complexion.

BENEFITS

- ✓ Highest possible level of protection
- ▼ Fast-absorbing SPF also features a high level of Niacinamide
- Reduces redness and blotchiness
- ✓ Increases firmness and elasticity
- Lightweight, leaves no residue
- An innovative new way to protect the skin against UV and IR
- ☑ Lightweight UVA and UVB broad spectrum protection

DIRECTIONS FOR USE

Apply to face & neck, avoiding the eye area. Wait at least 30 minutes before sun exposure, or as directed by a physician. Reapply after prolonged exposure, physical activity, perspiration or contact with water.

ACTIVE INGREDIENTS

Zinc Oxide 12.0%, Octinoxate 7.5%

INACTIVE INGREDIENTS

Water, Cyclopentasiloxane, Niacinamide (Vitamin B3), Oleth-3 Phosphate, Octyldodecyl Neopentanoate, Hydroxyethyl Acrylate/Sodium Acryloyldimethyl Taurate Copolymer, Polyisobutene, PEG-7 Trimethylolpropane Coconut Ether, Glycerin, Tocopheryl Acetate (Vitamin E), Polygonum Aviculare (Knotweed) Extract, Sodium Hyaluronate (Hyaluronic Acid), Disodium EDTA, Sodium Hydroxide, Citric Acid, Phenoxyethanol, Ethylhexylglycerin, Polyglyceryl-3 Polydimethylsiloxyethyl Dimethicone, Triethoxysilylethyl Polydimethylsiloxyethyl Hexyl Dimethicone, Triethoxycaprylylsilane